## **AMENDMENTS TO THE CLAIMS**

## Listing of claims:

This listing of claims replaces all prior versions and listings of claims in the application.

1. (Currently Amended) A process for producing a laminate comprising a polyimide and a conductor layer, which comprises

forming at least one conductor layer directly [[en]] adhering with at least one of the thermoplastic polyimide surfaces to obtain a laminate, and

heating said laminate after said laminate is formed so that a polyimide and a conductor layer are directly thermally fused and the adhesion strength between the thermoplastic polyimide and the conductor layer is enhanced.

2. (Currently Amended) A process for producing a laminate comprises a polyimide, a sheet material and a conductor layer, which comprises

casting or applying a polyamic acid corresponding to a thermoplastic polyimide to at least one of a sheet material surface,

imidating said polyamic acid to form a polyimide laminate having a thermoplastic polyimide surface,

forming at least one conductor layer directly [[en]] adhering with at least one of the thermoplastic polyimide surfaces to obtain a laminate, and

heating said laminate so that a polyimide and a conductor layer are directly thermally fused and the adhesion strength between the thermoplastic polyimide and the conductor layer is enhanced.

3. (Currently Amended) A process for producing a laminate comprises a polyimide, a sheet material and a conductor layer comprises

attaching at least one thermoplastic film to at least one of a sheet material surface to form a polyimide laminate having thermoplastic polyimide surface(s),

forming at least one conductor layer directly [[en]] adhering with at least one of the thermoplastic polyimide surfaces, and

heating said laminate so that a polyimide and a conductor layer are directly thermally fused and the adhesion strength between the thermoplastic polyimide and the conductor layer is enhanced.

- 4. (Original) The process according to claims 2 or 3, wherein said sheet material is a non-thermoplastic polyimide film.
- 5. (Original) The process according to any one of claims 1 to 3, wherein the thickness of said conductor layer is from 0.01 to 5  $\mu$ m.

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- 6. (Original) The process according to any one of claims 1 to 3, wherein the heating temperature is 50°C or higher.
- 7. (Original) The process according any one of claims 1 to 3, wherein the heating temperature is higher by 30°C or more than the glass transition temperature of the thermoplastic polyimide.
- 8. (Previously Presented) The process according to any one of claims 1 to 3, wherein said heating step is carried out under pressure.
- 9. (Original) The process according to claim 8, wherein the pressure at the pressurizing is 1MPa or more.
- 10. (Previously Presented) The process according to any one of claims 1 to 3, wherein said conductor layer is formed by a dry plating method.
- 11. (Original) The process according to claim 10, wherein said dry plating method is one selected from a group consisting of sputtering method, vacuum evaporation method, ion plating method and chemical evaporation method.

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12. (Original) The process according to claim 10, which further comprises increasing the total thickness of the conductor layer by a wet plating method.

13. (Original) The process according to any one of claims 1 to 3, wherein said conductor layer comprises copper.

14 – 16 (Canceled)

17. (Currently Amended) A process for producing a laminate comprising:

dry plating at least one conductor layer directly [[en]] adhering with at least one surface of a thermoplastic polyimide, and

heating said laminate so that the <u>adhesive strength between the</u> thermoplastic polyimide and the conductor layer <del>are directly thermally fused</del> is enhanced.

18. (Currently Amended) A process producing a laminate comprising:

providing a thermoplastic polyimide having at least one surface;

forming a conductor layer directly [[on]] adhering with said at least one surface; and

heating the thermoplastic polyimide and the formed conductor layer.